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INFORMATION DISCLOSURE STATEMENT (use several sheets if necessary)				APPLICANT Melissa K. Rath, et al.			
				FILING DATE March 3, 2004		GROUP 1756	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
le	AA	6,276,372	8/21/2001	Lee	134	1.3	
le	AB	6,242,400	6/5/2001	Lee	510	176	
le	AC	6,110,881	8/29/2000	Lee	510	175	
le	AD	5,709,756	1/20/1998	Ward, et al.	134	1.3	
le	AE	5,419,779	5/30/1995	Ward	134	38	
le	AF	20020128164	9/12/2002	Hara, Yasushi; et al.	510	175	11/30/2001
le	AG	6,329,118	12/11/2001	Hussein, et al.	430	270.1	
le	AH	10/389,214		Minsek, et al.	430	32A	3/14/2003
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY	CLASS	SUBCLAS S	TRANSLATION YES NO
							X (abstract only)
OTHER DOCUMENTS (Including Author, Title, Journal-Date, Page Number, Etc.)							
le	AI	Ito, "Dissolution Behavior of Chemically Amplified Resist Polymers for 248, 193-and 157 -nm Lithography, IBM J. Res. & Dev., Vol. 45 No. 5, (Sept. 2001)					
le	AJ	M. Hussein, et al. "A Novel Approach to Dual Damascene Patterning", Intel Corporation, Portland Technology Development, Hillsboro, OR					
Continue on Page							
EXAMINER Hoa Van Le					DATE CONSIDERED 25 May 2005		
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.							